



Attorney's Docket No.: 042390P9859

Patent

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:

Lawrence D. Wong

U.S. Serial No: 09/745,705

Filed: December 21, 2000

For: Structural Reinforcement of Highly  
Porous Low K Dielectric Films by  
ILD Posts

Examiner: Vu, Hung K.

Art Unit: 2811

Commissioner for Patents  
Washington, D.C. 20231

PRELIMINARY AMENDMENT AND RESPONSE

Dear Sir:

In response to the Final Office Action mailed August 20, 2002, Applicant respectfully submits a Request for Continued Examination, per 37 CFR 1.114, and further requests the Examiner to enter the following preliminary amendments and consider the following remarks.

FIRST CLASS CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage in an envelope addressed to the Assistant Commissioner of Patents, Washington, D.C. 21231

On November 7, 2002  
Date of Deposit

Teresa Edwards

Name of Person Mailing Correspondence

Teresa Edwards  
Signature

11/7/02  
Date